DOCKET NO: 292873US0PCT

## IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :

STEPHANE POCAS, ET AL. : EXAMINER: JONES, ERIC W.

SERIAL NO: 10/584,052 :

FILED: JUNE 22, 2006 : GROUP ART UNIT: 2892

FOR: METHOD OF SEALING TWO
PLATES WITH THE FORMATION OF AN
OHMIC CONTACT THERE BETWEEN

## RESPONSE TO RESTRICTION REQUIREMENT

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR:

Initially, Applicants note that the Restriction Requirement dated July 10, 2008 identifies only cancelled Claims 1-26, without considering newly added Claims 27-64. Claims 27-64 were introduced via the Preliminary Amendment filed July 25, 2006. In a telephone conversation between the Examiner and the undersigned representative on July 22, 2008, the Examiner indicated that Applicants should nevertheless respond to the outstanding Restriction Requirement.

Therefore, in response to the Restriction Requirement dated July 10, 2008, Applicants elect Group I, and Claims 1-19, 27-45 and 53-64 as reading on the elected method for the sealing processing for two wafers made of semiconducting materials. Claims 58-64 are included because Claim 58 depends from method Claim 27, and Claims 59-64 depend from Claim 58. Applicants make this election based on the understanding that Applicants are not prejudiced against filing one or more divisional applications that cover the non-elected invention.

Application No. 10/584,052 Reply to Office Action of July 10, 2008

Accordingly, it is respectfully requested that a full examination on the merits of Claims 27-45 and 53-64 be conducted.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C. Norman F. Oblon

 $\begin{array}{c} \text{Customer Number} \\ 22850 \end{array}$ 

Tel: (703) 413-3000 Fax: (703) 413 -2220 (OSMMN 08/07) Philippe J.C. Signore, Ph.D.

Attorney of Record Registration No. 43,922